

(12) INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(19) World Intellectual Property
Organization
International Bureau



(43) International Publication Date
17 June 2004 (17.06.2004)

PCT

(10) International Publication Number
WO 2004/051738 A2

(51) International Patent Classification⁷: **H01L 21/762**

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(21) International Application Number:
PCT/IB2003/004937

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(22) International Filing Date: 31 October 2003 (31.10.2003)

(81) Designated States (*national*): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW.

(25) Filing Language: English

(84) Designated States (*regional*): ARIPO patent (GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PT, RO, SE, SI, SK, TR), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

(26) Publication Language: English

(30) Priority Data:
02080057.9 3 December 2002 (03.12.2002) EP

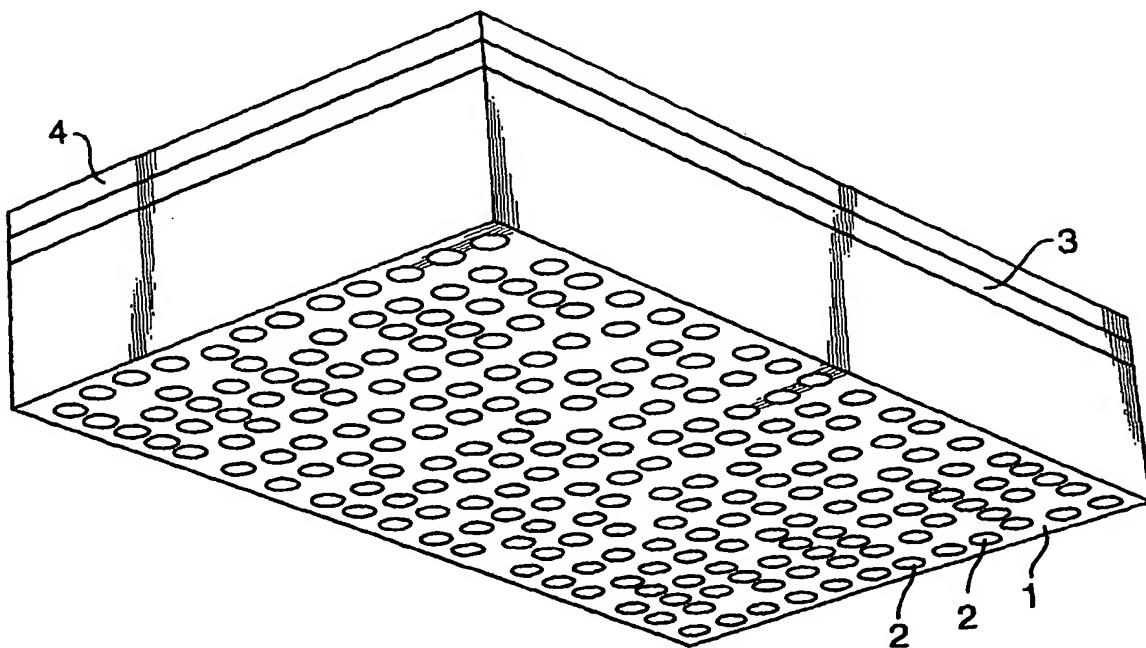
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(54) Title: METHOD FOR THE MANUFACTURE OF A DISPLAY



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(57) Abstract: A method for the manufacture of displays, in particular flexible displays, is disclosed. A substrate (1) provided with small openings (2), rendering the substrate porous and forming trenches in the substrate (1), is used. A removable layer (3) is attached to the substrate (1). An etch and temperature resistant layer (4) is deposited onto the removable layer (3), and a display is processed on said etch and temperature resistant layer (4). The removable layer (3) is removed by etching through the openings (2) in the substrate (1) and the substrate may be re-used.